

[TS13W2]**Nanofabrication Process and Platform 2**

Date & Time	July 3(Wed.), 2024 / 15:40–17:55
Place	Room 212
Session Chair(s)	Kwanoh Kim (KIMM), Hyun-Mi Kim (KETI)

TS13W2_I_1 *Invited 15:40–16:10**Driving Innovation through Advanced Material Solutions for Micro–Nano–Fabrication**

M. Russew, C. Schuster, A. Voigt, M. Lohse, M. Heinrich, A. Schleunitz, and G. Grützner
(micro resist technology GmbH)

TS13W2_I_2 *Invited 16:10–16:40**Laser Processing of Graphene Electrodes for High–Performance Energy Storage Devices**

Soongeun Kwon^{1,2}
(¹KIMM, ²UST)

TS13W2_I_3 *Invited 16:40–17:10**Platform Technology for Enhanced Performance of Contact Electrification Based Electricity Generator**

Dongwhi Choi
(Kyung Hee University)

TS13W2_O_4 17:10–17:25**High–Density, Moisture Impermeable TiO₂ Layer Fabricated by an Unconventional Approach**

Jaeun Lim¹, Jeong–Eun Chae², and Dooho Choi³
(¹Dong–Eui University, ²GERI, ³Gachon University)

TS13W2_O_5 17:25–17:40**Chemically Altered Ag/ZnO Interface for Remarkable Performance Enhancement of Transparent Electrodes**

Heechang Kim¹, Jeong–Eun Chae², and Dooho Choi³
(¹Dong–Eui University, ²GERI, ³Gachon University)

TS13W2_O_6 17:40–17:55**Photo–Cationic Polymerizable Ceramic Slurry for the Fabrication of Ceramic Structures in Vat Polymerization Based Ceramic 3D Printing**

Hye–Yeong Park^{1,2}, Yeon–Gil Jung², and SeungCheol Yang²
(¹KIMS, ²Changwon National University)